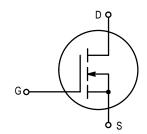
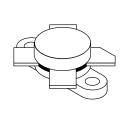
The RF MOSFET Line **RF Power Field-Effect Transistor** N–Channel Enhancement–Mode

Designed primarily for linear large-signal output stages up to 150 MHz frequency range.

- Specified 50 Volts, 30 MHz Characteristics Output Power = 150 Watts Power Gain = 17 dB (Typ) Efficiency = 45% (Typ)
- Superior High Order IMD
- IMD(d3) (150 W PEP) -32 dB (Typ)
- IMD_(d11) (150 W PEP) -60 dB (Typ)
- 100% Tested For Load Mismatch At All Phase Angles With 30:1 VSWR





MRF150

150 W, to 150 MHz

N-CHANNEL MOS LINEAR RF POWER

FET

CASE 211-11, STYLE 2

MAXIMUM RATINGS

Rating	Symbol	Value	Unit
Drain–Source Voltage	V _{DSS}	125	Vdc
Drain–Gate Voltage	VDGO	125	Vdc
Gate-Source Voltage	V _{GS}	±40	Vdc
Drain Current — Continuous	۱ _D	16	Adc
Total Device Dissipation @ T _C = 25°C Derate above 25°C	PD	300 1.71	Watts W/°C
Storage Temperature Range	T _{stg}	-65 to +150	°C
Operating Junction Temperature	Тј	200	°C
THERMAL CHARACTERISTICS	, , , , , , , , , , , , , , , , , , ,		

Characteristic	Symbol	Мах	Unit
Thermal Resistance, Junction to Case	R _θ JC	0.6	°C/W

Handling and Packaging — MOS devices are susceptible to damage from electrostatic charge. Reasonable precautions in handling and packaging MOS devices should be observed.



Characteristic	Symbol	Min	Тур	Max	Unit
OFF CHARACTERISTICS					
Drain–Source Breakdown Voltage (V_{GS} = 0, I_D = 100 mA)	V _(BR) DSS	125	—	—	Vdc
Zero Gate Voltage Drain Current (VDS = 50 V, VGS = 0)	IDSS	_	—	5.0	mAdc
Gate–Body Leakage Current (V _{GS} = 20 V, V _{DS} = 0)	IGSS	_	—	1.0	μAdc
ON CHARACTERISTICS					
Gate Threshold Voltage (V _{DS} = 10 V, I _D = 100 mA)	V _{GS(th)}	1.0	3.0	5.0	Vdc
Drain–Source On–Voltage (V_{GS} = 10 V, I _D = 10 A)	V _{DS(on)}	1.0	3.0	5.0	Vdc
Forward Transconductance (V _{DS} = 10 V, I _D = 5.0 A)	9fs	4.0	7.0	—	mhos
OYNAMIC CHARACTERISTICS					
Input Capacitance (V_{DS} = 50 V, V_{GS} = 0, f = 1.0 MHz)	C _{iss}	—	450	—	pF
Output Capacitance (V_{DS} = 50 V, V_{GS} = 0, f = 1.0 MHz)	C _{OSS}	_	250	—	pF
Reverse Transfer Capacitance (V_{DS} = 50 V, V_{GS} = 0, f = 1.0 MHz)	C _{rss}	_	40	—	pF
UNCTIONAL TESTS (SSB)					
	G _{ps}	_	17 8.0	_	dB
Drain Efficiency $(V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W} \text{ (PEP)}, f = 30; 30.001 \text{ MHz}, I_D (Max) = 3.75 \text{ A})$	η	_	45	_	%
Intermodulation Distortion (1) ($V_{DD} = 50 \text{ V}, P_{out} = 150 \text{ W} (PEP),$ f1 = 30 MHz, f2 = 30.001 MHz, I _{DQ} = 250 mA)	IMD _(d3) IMD _(d11)		-32 -60	_	dB
Load Mismatch (V _{DD} = 50 V, P _{out} = 150 W (PEP), f = 30; 30.001 MHz, I _{DQ} = 250 mA, VSWR 30:1 at all Phase Angles)	Ψ	No Degradation in Output Power			

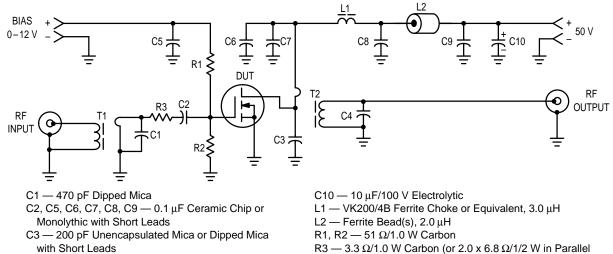
ELECTRICAL CHARACTERISTICS (T_C = 25°C unless otherwise noted.)

CLASS A PERFORMANCE

Intermodulation Distortion (1) and Power Gain	GPS	_	20	_	dB
(V _{DD} = 50 V, P _{out} = 50 W (PEP), f1 = 30 MHz,	IMD _(d3)	—	-50	—	
f2 = 30.001 MHz, I _{DQ} = 3.0 A)	IMD(d9-13)	—	-75	—	

NOTE:

1. To MIL-STD-1311 Version A, Test Method 2204B, Two Tone, Reference Each Tone.



C4 — 15 pF Unencapsulated Mica or Dipped Mica with Short Leads

T1 — 9:1 Broadband Transformer

T2 — 1:9 Broadband Transformer



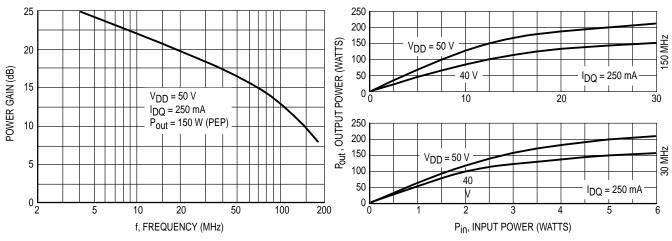


Figure 2. Power Gain versus Frequency

Figure 3. Output Power versus Input Power

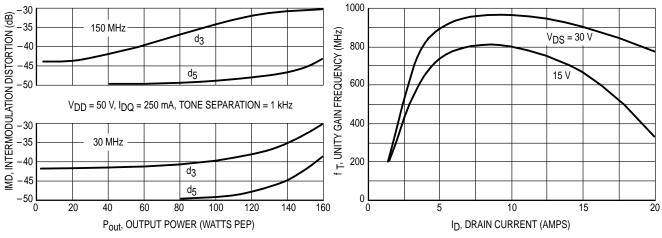


Figure 4. IMD versus Pout

Figure 5. Common Source Unity Gain Frequency versus Drain Current

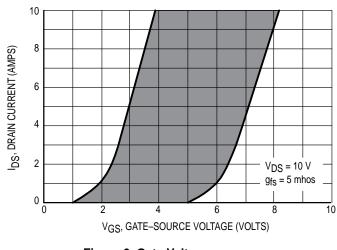
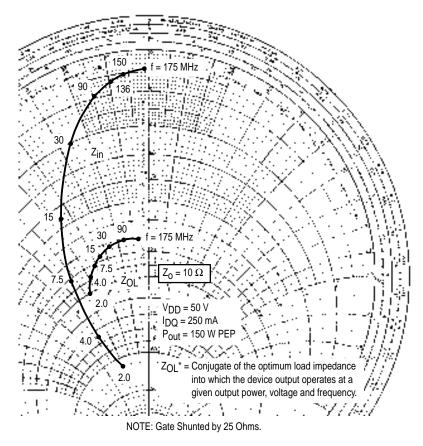
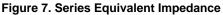


Figure 6. Gate Voltage versus Drain Current





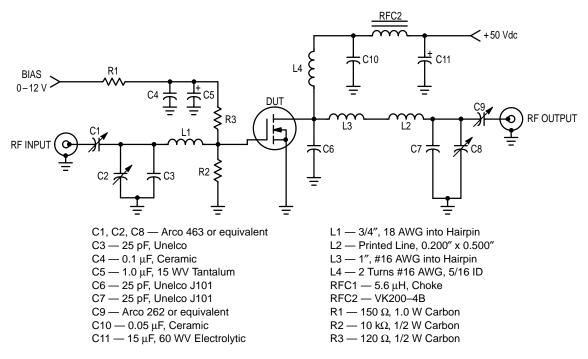


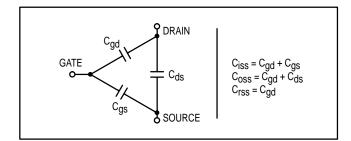
Figure 8. 150 MHz Test Circuit (Class AB)

MOSFET CAPACITANCES

The physical structure of a MOSFET results in capacitors between the terminals. The metal oxide gate structure determines the capacitors from gate–to–drain (C_{gd}), and gate–to–source (C_{gs}). The PN junction formed during the fabrication of the RF MOSFET results in a junction capacitance from drain–to–source (C_{ds}).

These capacitances are characterized as input (C_{iSS}), output (C_{OSS}) and reverse transfer (C_{rSS}) capacitances on data sheets. The relationships between the inter-terminal capacitances and those given on data sheets are shown below. The C_{iSS} can be specified in two ways:

- 1. Drain shorted to source and positive voltage at the gate.
- Positive voltage of the drain in respect to source and zero volts at the gate. In the latter case the numbers are lower. However, neither method represents the actual operating conditions in RF applications.



LINEARITY AND GAIN CHARACTERISTICS

In addition to the typical IMD and power gain data presented, Figure 5 may give the designer additional information on the capabilities of this device. The graph represents the small signal unity current gain frequency at a given drain current level. This is equivalent to f_T for bipolar transistors.

Since this test is performed at a fast sweep speed, heating of the device does not occur. Thus, in normal use, the higher temperatures may degrade these characteristics to some extent.

DRAIN CHARACTERISTICS

One figure of merit for a FET is its static resistance in the full–on condition. This on–resistance, $V_{DS(on)}$, occurs in the linear region of the output characteristic and is specified under specific test conditions for gate–source voltage and drain current. For MOSFETs, $V_{DS(on)}$ has a positive temperature coefficient and constitutes an important design consideration at high temperatures, because it contributes to the power dissipation within the device.

GATE CHARACTERISTICS

The gate of the RF MOSFET is a polysilicon material, and is electrically isolated from the source by a layer of oxide. The input resistance is very high — on the order of 10^9 ohms — resulting in a leakage current of a few nanoamperes.

Gate control is achieved by applying a positive voltage slightly in excess of the gate-to-source threshold voltage, VGS(th).

Gate Voltage Rating — Never exceed the gate voltage rating. Exceeding the rated V_{GS} can result in permanent damage to the oxide layer in the gate region.

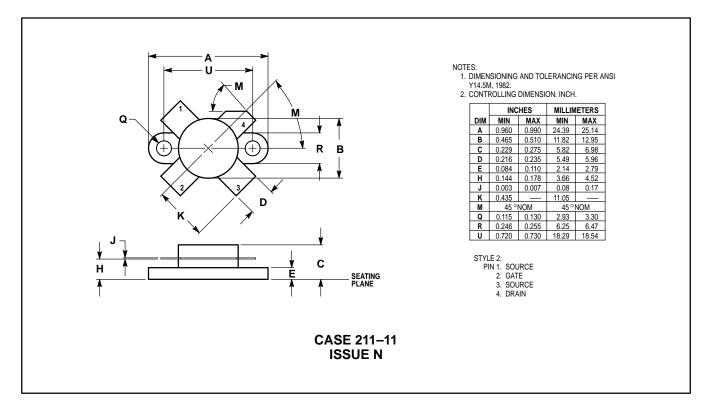
Gate Termination — The gates of these devices are essentially capacitors. Circuits that leave the gate open-circuited or floating should be avoided. These conditions can result in turn-on of the devices due to voltage build-up on the input capacitor due to leakage currents or pickup.

Gate Protection — These devices do not have an internal monolithic zener diode from gate-to-source. If gate protection is required, an external zener diode is recommended.

EQUIVALENT TRANSISTOR PARAMETER TERMINOLOGY

Emitter Base V(BR)CES VCBO IC ICES IEBO VBE(on) VCE(sat) Cib	Source Gate V(BR)DSS VDGO ID IDSS IGSS VGS(th) VDS(on) Ciss Coss
$R_{CE(sat)} = \frac{V_{CE(sat)}}{I_C} \dots$	 $r_{DS(on)} = \frac{V_{DS(on)}}{I_D}$

PACKAGE DIMENSIONS



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HONG KONG: Motorola Semiconductors H.K. Ltd.; 8B Tai Ping Industrial Park, 51 Ting Kok Road, Tai Po, N.T., Hong Kong. 852–26629298

